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(54) **IMPLANT, IMPLANT BODY, ABUTMENT BODY**

(57) An implant (5) includes an implant body (10) in which a fitting hole portion (14) having a taper shape is formed, and an abutment (20) having a fitting shaft portion (22) having a taper shape. A pressure-withstanding mechanism (60) configured by the fitting hole portion (14) and the fitting shaft portion (22) and a rotation-preventing mechanism (70) preventing rotation of the abutment (20) with respect to the implant body (10) are integrally formed.

FIG. 4

